Martin Hafermann

List of Publications by Year in descending order

Source: https://exaly.com/author-pdf/4206477/publications.pdf

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		1478505	1372567	
10	175	6	10	
papers	citations	h-index	g-index	
10	10	10	160	
all docs	docs citations	times ranked	citing authors	

#	Article	IF	CITATIONS
1	A photonic integrated circuit–based erbium-doped amplifier. Science, 2022, 376, 1309-1313.	12.6	95
2	Revealing the origin of the beneficial effect of cesium in highly efficient Cu(In,Ga)Se2 solar cells. Nano Energy, 2020, 71, 104622.	16.0	25
3	Flat Optical and Plasmonic Devices Using Areaâ€6elective Ionâ€Beam Doping of Silicon. Advanced Optical Materials, 2018, 6, 1701027.	7. 3	12
4	Metasurfaces Enabled by Locally Tailoring Disorder in Phase-Change Materials. ACS Photonics, 2018, 5, 5103-5109.	6.6	12
5	Tuning carrier density and phase transitions in oxide semiconductors using focused ion beams. Nanophotonics, 2022, 11 , 3923-3932.	6.0	10
6	In-Operando Nanoscale X-ray Analysis Revealing the Local Electrical Properties of Rubidium-Enriched Grain Boundaries in Cu(In,Ga)Se ₂ Solar Cells. ACS Applied Materials & Interfaces, 2020, 12, 57117-57123.	8.0	7
7	Grayscale Nanopatterning of Phase-Change Materials for Subwavelength-Scaled, Inherently Planar, Nonvolatile, and Reconfigurable Optical Devices. ACS Applied Nano Materials, 2020, 3, 4486-4493.	5.0	7
8	Hot electrons in a nanowire hard X-ray detector. Nature Communications, 2020, 11, 4729.	12.8	4
9	Fast recovery of ion-irradiation-induced defects in Ge ₂ Sb ₂ Te ₅ thin films at room temperature. Optical Materials Express, 2021, 11, 3535.	3.0	2
10	Embedded Optics: Flat Optical and Plasmonic Devices Using Areaâ€6elective Ionâ€8eam Doping of Silicon (Advanced Optical Materials 5/2018). Advanced Optical Materials, 2018, 6, 1870019.	7.3	1